L Number	Hits	Search Text	DB	Time stamp
-	2	6383300.pn.	USPAT;	2004/02/20 14:52
			US-PGPUB;	
			EPO; JPO;	
	•		DERWENT;	
			IBM_TDB	
-	17	("4699805"   "5015503"   "5250092"   "5328360"	USPAT	2004/02/20 15:47
		"5433784"   "5554226"   "5578132"   "5637153"		
		"5777300"   "5851293"   "5880032"   "5914000"		
·	,	"6099649"   "6139642"   "6159298"   "6206971"		
		"6238514").PN.		
-	17961	((118/715,724,725) or (156/345.29) or (134/1,1.3) or	USPAT;	2004/02/20 16:17
·		(216/37,58,63) or (438/694,699,703,706)).CCLS.	US-PGPUB;	
	·		EPO; JPO;	·
			DERWENT;	
			IBM_TDB	
_	550	(((118/715,724,725) or (156/345.29) or (134/1,1.3) or	USPAT;	2004/02/20 17:29
		(216/37,58,63) or (438/694,699,703,706)).CCLS.) and	US-PGPUB;	
		((first with (film or coating or layer)) or ((silicon adj oxide)	EPO; JPO;	
		or SiO)) and ((second with (film or coating or layer)) or	DERWENT;	
	·	((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3) same	IBM_TDB	·
		((hydrogen adj fluoride) or HF))		
-	419	((((118/715,724,725) or (156/345.29) or (134/1,1.3) or	USPAT;	2004/02/20 18:02
		(216/37,58,63) or (438/694,699,703,706)).CCLS.) and	US-PGPUB;	' '
		((first with (film or coating or layer)) or ((silicon adj oxide)	EPO; JPO;	
		or SiO)) and ((second with (film or coating or layer)) or	DERWENT;	
		((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3) same	IBM_TDB	
		((hydrogen adj fluoride) or HF))) and (@ad<=19991124 or		
		@rlad<=19991124)		
_	384	((((((118/715,724,725) or (156/345.29) or (134/1,1.3) or	USPAT;	2004/02/20 17:33
		(216/37,58,63) or (438/694,699,703,706)).CCLS.) and	US-PGPUB;	' '
		((first with (film or coating or layer)) or ((silicon adj oxide)	EPO; JPO;	
•		or SiO)) and ((second with (film or coating or layer)) or	DERWENT;	
		((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3) same	IBM_TDB	.
٠		((hydrogen adj fluoride) or HF))) and (@ad<=19991124 or		
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)	-	
		with dip)		
_	5	("5545291"   "5904545"   "5958794"   "6468638"	USPAT	2004/02/20 16:42
		"6479395").PN.		
-	163	((((((118/715,724,725) or (156/345.29) or (134/1,1.3) or	USPAT;	2004/02/20 17:33
	_	(216/37,58,63) or (438/694,699,703,706)).CCLS.) and	US-PGPUB;	' '
		((first with (film or coating or layer)) or ((silicon adj oxide)	EPO; JPO;	
		or SiO)) and ((second with (film or coating or layer)) or	DERWENT;	
		((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3) same	IBM_TDB	
		((hydrogen adj fluoride) or HF))) and (@ad<=19991124 or	_	
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)		
		with (dip or solution or wet))		
_	991	((first with (film or coating or layer)) or ((silicon adj oxide)	USPAT;	2004/02/20 17:56
		or SiO)) and ((second with (film or coating or layer)) or	US-PGPUB;	
		((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3) same	EPO; JPO;	
		((hydrogen adj fluoride) or HF) same (tube or wall or	DERWENT;	
-		exhaust or bell)	IBM_TDB	
-	749	(((first with (film or coating or layer)) or ((silicon adj oxide)	USPAT;	2004/02/20 17:32
	, .5	or SiO)) and ((second with (film or coating or layer)) or	US-PGPUB;	,,
		((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3) same	EPO; JPO;	
		((hydrogen adj fluoride) or HF) same (tubé or wall or	DERWENT;	
		exhaust or bell) )) and (@ad<=19991124 or	IBM_TDB	
		@rlad<=19991124)		

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	319	((((first with (film or coating or layer)) or ((silicon adj oxide)	USPAT;	2004/02/20 18:02
_	319	or SiO)) and ((second with (film or coating or layer)) or	US-PGPUB;	200 1/02/20 10.02
		((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3) same	EPO; JPO;	
		((hydrogen adj fluoride) or HF) same (tube or wall or	DERWENT;	
		exhaust or bell) )) and (@ad<=19991124 or	IBM_TDB	
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)		
		with (dip or solution or wet))		
-	284	(((((first with (film or coating or layer)) or ((silicon adj	USPAT;	2004/02/20 17:34
		oxide) or SiO)) and ((second with (film or coating or layer))	US-PGPUB;	
		or ((silicon adj nitride) or SiN)) and ((clean\$3 or etch\$3)	EPO; JPO;	
		same ((hydrogen adj fluoride) or HF) same (tube or wall or	DERWENT;	
		exhaust or bell) )) and (@ad<=19991124 or	IBM_TDB	
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)		
		with (dip or solution or wet))) not ((((((118/715,724,725) or		
		(156/345.29) or (134/1,1.3) or (216/37,58,63) or		
		(438/694,699,703,706)).CCLS.) and ((first with (film or		
		coating or layer)) or ((silicon adj oxide) or SiO)) and		
		((second with (film or coating or layer)) or ((silicon adj		
	į	nitride) or SiN)) and ((clean\$3 or etch\$3) same ((hydrogen		
		adj fluoride) or HF))) and (@ad<=19991124 or		
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)		
		with (dip or solution or wet)))	:	
_	2215	((first with (film or coating or layer)) or ((silicon adj oxide)	USPAT;	2004/02/20 18:01
		or SiO)) and ((second with (film or coating or layer)) or	US-PGPUB;	2001,02,2010101
		((silicon adj nitride) or SiN)) and ((clean\$3) same (tube or	EPO; JPO;	
		chamber or wall or exhaust or bell)) and ((hydrogen adj	DERWENT;	
		fluoride) or HF)	IBM TDB	
_	676	(((first with (film or coating or layer)) or ((silicon adj oxide)	USPAT;	2004/02/20 18:02
_	0,0	or SiO)) and ((second with (film or coating or layer)) or	US-PGPUB;	200 1/02/20 10.02
		((silicon adj nitride) or SiN)) and ((clean\$3) near5 (tube or	EPO; JPO;	
			DERWENT;	
		chamber or wall or exhaust or bell)) and ((hydrogen adj	IBM_TDB	
		fluoride) or HF)) and (@ad<=19991124 or	TDM_1DD	
	463	@rlad<=19991124)	LICDAT.	2004/02/20 10:02
-	462	((((first with (film or coating or layer)) or ((silicon adj oxide)	USPAT;	2004/02/20 18:03
		or SiO)) and ((second with (film or coating or layer)) or	US-PGPUB;	
		((silicon adj nitride) or SiN)) and ((clean\$3) near5 (tube or	EPO; JPO;	*
		chamber or wall or exhaust or bell)) and ((hydrogen adj	DERWENT;	
		fluoride) or HF)) and (@ad<=19991124 or	IBM_TDB	
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)		
		with (dip or solution or wet))		
-	980	((first with (film or coating or layer)) or ((silicon adj oxide)	USPAT;	2004/02/20 18:06
		or SiO)) and ((second with (film or coating or layer)) or	US-PGPUB;	-
		((silicon adj nitride) or SiN)) and ((clean\$3) near5 (tube or	EPO; JPO;	
		chamber or wall or exhaust or bell)) and ((hydrogen adj	DERWENT;	
		fluoride) or HF)	IBMTDB	

			<del></del>	
-	293	((((((first with (film or coating or layer)) or ((silicon adj	USPAT;	2004/02/20 18:10
		oxide) or SiO)) and ((second with (film or coating or layer))	US-PGPUB;	
		or ((silicon adj nitride) or SiN)) and ((clean\$3) near5 (tube	EPO; JPO;	
		or chamber or wall or exhaust or bell)) and ((hydrogen adj	DERWENT;	
-		fluoride) or HF)) and (@ad<=19991124 or	IBM_TDB	
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)	_	
		with (dip or solution or wet))) not ((((((118/715,724,725)		
		or (156/345.29) or (134/1,1.3) or (216/37,58,63) or		
		(438/694,699,703,706)).CCLS.) and ((first with (film or		
		coating or layer)) or ((silicon adj oxide) or SiO)) and		
		((second with (film or coating or layer)) or ((silicon adj		
		nitride) or SiN)) and ((clean\$3 or etch\$3) same ((hydrogen		
		adj fluoride) or HF))) and (@ad<=19991124 or		
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)		
		with (dip or solution or wet))) or (((((first with (film or		
		coating or layer)) or ((silicon adj oxide) or SiO)) and		
		((second with (film or coating or layer)) or ((silicon adj		
		nitride) or SiN)) and ((clean\$3 or etch\$3) same ((hydrogen	'	
		adj fluoride) or HF) same (tube or wall or exhaust or bell) ))		
	٠	and (@ad<=19991124 or @rlad<=19991124)) not		
ľ		(((hydrogen adj fluoride) or HF) with (dip or solution or	*	
		wet))) not (((((((118/715,724,725) or (156/345.29) or		ĺ
		(134/1,1.3) or (216/37,58,63) or		
		(438/694,699,703,706)).CCLS.) and ((first with (film or		
		coating or layer)) or ((silicon adj oxide) or SiO)) and		
		((second with (film or coating or layer)) or ((silicon adj		
		nitride) or SiN)) and ((clean\$3 or etch\$3) same ((hydrogen		
		adj fluoride) or HF))) and (@ad<=19991124 or		
		@rlad<=19991124)) not (((hydrogen adj fluoride) or HF)		
		with (dip or solution or wet)))))) not (wet adj etch\$3)		
-	980	exhaust same (fluctuat\$3 with pressure)	USPAT;	2004/02/23 15:56
1			US-PGPUB;	
	1		EPO; JPO;	
-			DERWENT;	
			IBM_TDB	
	25	(avhaust same (flustuate2 with prossure)) and 110 class	USPAT;	2004/02/23 16:34
-	25	(exhaust same (fluctuat\$3 with pressure)) and 118.clas.		2004/02/23 10:34
			US-PGPUB;	
			EPO; JPO;	
İ			DERWENT;	
			IBM_TDB	
-	17	("4699805"   "5015503"   "5250092"   "5328360"	USPAT	2004/02/23 16:09
		**************************************		
		"5777300"   "5851293"   "5880032"   "5914000"		
		"6099649"   "6139642"   "6159298"   "6206971"		
	]	"6238514").PN.	LICDAT	2004/02/22 46:45
-	26	control\$3 same pressure same (exhaust adj pipe) same	USPAT;	2004/02/23 16:45
		fluctuat\$3	US-PGPUB;	
1			EPO; JPO;	
	·		DERWENT;	
			IBM_TDB	
]_	80	pressuré same (exhaust adj pipe) same fluctuat\$3	USPAT;	2004/02/23 16:47
		pressure same (exhicast day pipe) same nactadigs	US-PGPUB;	200 1, 02, 23 10. 17
i	1			
			EPO; JPO;	
-			DERWENT;	
			IBM_TDB	
	54	(pressure same (exhaust adj pipe) same fluctuat\$3) not	USPAT;	2004/02/23 17:13
1		(control\$3 same pressure same (exhaust adj pipe) same	US-PGPUB;	
		fluctuat\$3)	EPO; JPO;	
		······································	DERWENT;	
			IBM_TDB	
1 .	1	<u> </u>	ַםטו_וייוטד	

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-	2749	purge same repeat\$3	USPAT;	2004/02/23 17:16
			US-PGPUB;	·
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	·
-	10	(purge same repeat\$3) same (exhaust adj pipe)	USPAT;	2004/02/23 17:17
			US-PGPUB;	
			EPO; JPO;	
		·	DERWENT;	
			IBM_TDB	